

## **Purge and Trap/GC/MS Analysis** of Volatile Organic Compounds: Advances in Sample Throughput

Christopher English, Restek Corporation

Purge and trap cycle time is the limiting factor in volatile organics analysis by gas chromatography/mass spectrometry. To overcome these time limitations, two purge and trap units, each with its own autosampler unit, can be connected to a single GC/MS. With this system, and a chromatography column designed to separate compounds that share common ions, it is possible to analyze 80 samples in 24 h.

emand for increased productivity in volatile organics analysis (VOA) by gas chromatography/mass spectrometry (GC/MS) has resulted in the creation of automated water and soil autosamplers that enable environmental laboratories to operate purge and trap systems around the clock. Still, laboratories seek faster turn-around-time, for better customer service and return on

Compounds in 5 mil of 80 water. Concentrator. Tekmar LSC-3100 Purge and Trap Vocarb® 3000 (type K) That is Purge: 11 min € 40 mL/min € ambient temperabure Dry purge: 1 min @40 mL/min Desorts prehent: 245 °C 250 °C for 2 min, Flow 40 mL/min Desorb 260 °C for 8 min Baite Interface 0.53 mm t.d. Sikooteel® transfer line 1:40 split at injection port. 1 mm i.d. liner 50 °C (hold 4 min) to 100 °C @ 13 °Omin (hold 0 min) Oven temp. to 230 °C @ 40 °C/min (hold 3 min) Carrier gas: Helium @~1.0 mL/min constant flow Adjust dichloro diffuor omethane (1) to a retention time of 1.03 min @50 PC Aditent 5973 MSD Detector Scan range 35-300 amu Time (min)

Figure 1: Volatile organics by U.S. EPA Method 8260B. Column: Rtx<sup>®</sup>-VMS (Restek Corp., cat. # 49914), 20 m, 0.18 mm i.d., 1.00  $\mu$ m film; conditions listed on figure. Peaks: 30 = dibromofluoromethane (SMC), 36 = pentafluorobenzene (IS), 42 = 1,4-difluorobenzene (SMC), 50 = toluene-d8 (SMC), 64 = chlorobenzene-d5 (IS), 74 = 4-bromo-1-fluorobenzene (SMC), 88 = 1,4-dichlorobenzene-d4 (IS).

capital equipment investments. This need has resulted in a push to develop columns that drastically reduce analysis time and instruments that accommodate short cycle times.

Currently, the limiting factor in VOA is the purge and trap cycle time: it includes an 11-min purge time followed by a 6-12 min bake-out time. A modern GC, on the other hand, can acquire a sample in 10 min or less. To ove roome the time limitations of the purge and trap cycle, two purge and trap units, each with its own autosampler unit, can be connected to a single GC/MS operating system (1). The concentrators are synchronized so that while one is desorbing a sample onto the column for analysis, the other completes the bake cycle and begins to purge the next sample. A Du e t® interface (Tekmar-Dohrmann, Mason, Ohio) gates the signals between the two concentrators, to prevent a faster concentrator from overtaking a slightly slower one. Calibration curves and quality control samples (QC, MS, MSD) must be run for each concentrator. A tracer compound is added to samples from one of the concentrators, to eliminate any question as to which purge and trap system provided a particular sample.

Using this system and a computer-designed chromatography column, tuned specifically for separating compounds that share common ions and typically coelute on columns intended for VOA, it is possible to analyze 80 samples in 24 h, a significant increase in output from a single GC/MS instrument. Figure 1 shows an analysis on an Rtx<sup>®</sup>-VMS column according to US EPA Method 8260B, including the specified internal standards and surrogates.

For additional information about VOA procedures, refer to (1) and to technical guide Optimizing the Analysis of Volatile Organic Compounds published by Restek Corporation (2).

## References

- (1) A.L. Hilling and G. Smith, Environmental Testing & Analysis 10(3), 15-19
- Optimizing the Analysis of Volatile Organic Compounds, lit. cat. # 59887A (Restek Corp., Bellefonte, PA, 2003).

## **Restek Corporation**

110 Benner Circle, Bellefonte, PA USA 16823 tel. (800) 356-1688 or (814) 353-1300, fax (814) 353-1309 www.restekcorp.com